## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:			Examiner: Unassigned			
MINEO SHIMOTSUSA, ET AL.						
Application No.: 10/657,269			Group Art Unit: 2811			
Filed: September 9, 2003						
For:	SEMICONDUCTOR DEVICE, METHOD FOR MANUFACTURING THE SAME, AND LIOUID JET APPARATUS	; ; )	April 13, 2004			

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## INFORMATION DISCLOSURE STATEMENT

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO-1449. Copies of the listed documents, together with English-language translations, are enclosed.

The listed documents were previously cited in the Information Disclosure Statement dated September 8, 2003. However, these documents are being cited again here, since English-language translations are now being provided.

The Examiner's attention is also directed to the following document:

Korean Office Action dated January 28, 2004, in KR-2001-0086492.

The Korean Office Action issued in a Korean application corresponding to the subject application. The Korean Office Action cites the documents listed on the Form PTO-1449. Since a copy of the Korean Office Action was submitted with the Letter filed March 8, 2004, a copy is not being provided here.

Applicants submit that the Korean Office Action can be summarized as follows:

Japan 62-98764 discloses a method of manufacturing a CMOS type semiconductor device, and Japan 8-97410 discloses a method of manufacturing a self-aligned lateral D-MOS transistor.

## **FORMAL MATTERS**

In accordance with 37 C.F.R. § 1.97(b), since a first Office Action on the merits of the subject application has not yet been issued, neither a statement under 37 C.F.R. § 1.97(e) nor payment of a fee is believed to be required for consideration of this Information Disclosure Statement. However, the Commissioner is hereby authorized to charge any fee which may be required in connection with this paper to Deposit Account No. 06-1205. A duplicate of this paper is enclosed for that purpose.

## **CONCLUSION**

It is respectfully requested that the above information be considered by the Examiner and that a copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

Applicants' undersigned attorney may be reached in our Washington D.C. office by telephone at (202) 530-1010. All correspondence should continue to be directed to our address given below.

Respectfully submitted,

Attorney for Applicants Damond E. Vadnais

Registration No. 52,310

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FORM PTO 1449 (modified)  U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE  LIST OF REFERENCES CITED BY APPLICANT(S) (Use several sheets if necessary)  Date Submitted to PTO: April 13, 2004			ATTY	O3500.016072.1	APPLICA	PLICATION NO. 10/657,269					
			APPL	APPLICANT MINEO SHIMOTSUSA, ET AL.							
			FILIN	FILING DATE September 9, 2003			GROUP <b>2811</b>				
			U.S. PA	ATENT DOCUMENTS							
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE		NAME	CLAS	SUBCLASS	FILING DATE IF APPROPRIATE				
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APR 1 3 2004											
TRADEMARY											
		I	FOREIGN	PATENT DOCUMENTS							
	DOCUMENT DATE NUMBER			COUNTRY		SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT				
	62-98764	05/08/1997		Japan			Yes				
	8-97410	04/12/1996		Japan			Yes				
		OTHER DOCUMEN	T(S) (Includ	ding Author, Title, Date, Pertinent Pages, Etc.)	-						
						-					
EXAMINER				DATE CONSIDERED	-						

<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.